

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of: Anthony et al.

Docket: TI-24953

Serial No.: 09/116,138

Examiner: B. Su

Filed: 07/15/98

Art Unit: 2814

For: High Permittivity Silicate Gate Dielectric

#10 (EX-10  
Time(s)  
TJL  
B-22-99)

## Petition For Extension of Time Under 37 C.F.R. § 1.136

December 20, 1999

Assistant Commissioner For Patents  
Washington, D. C. 20231

FACSIMILE CERTIFICATE  
I hereby certify that this correspondence is being transmitted by Facsimile to the Patent and Trademark Office in accordance with 37 C.F.R. §1.6d on December 20, 1999.



David Denker, Reg. No. 40,987

Dear Sir:

Pursuant to 37 C.F.R. 1.136(a) Applicants respectfully petition the Commissioner for a one month extension of the shortened statutory period for response in the above-identified application.

Please charge this and any other required fee to the deposit account of Texas Instruments Incorporated, Account No. 20-0668. Any further necessary extension of time is hereby requested.

Respectfully submitted,


David Denker  
Reg. No. 40,987

FAX COPY RECEIVED

DEC 20 1999

TECHNOLOGY CENTER 2800

Texas Instruments Incorporated  
P. O. Box 655474, MS 3999  
Dallas, Texas 75265  
(972) 917-4388  
Fax (972) 917-4418

12/23/1999 TTUBBS 09009003 200668 09116138  
01 FC:115 110.00 CH